

Claim 19. (new)

A method according to claim 12 wherein said microorganism is Legionellae.

Claim 20. (new)

A method according to claim 12 wherein said microorganism is mold and mold spores.

Claim 21. (new)

A method according to claim 13 wherein said chlorine is present in said mixture of chlorine and argon in an amount of about 1.0 to 3% by partial pressure of the total mixture.

Claim 22. (new)

A method according to claim 13 wherein said chlorine is present in said mixture of chlorine and argon in an amount of 0.1% to 25% by partial pressure of the total mixture.

Remarks

The above claims are directed to the non-elected invention, which is removing microorganisms with a chlorine/noble gas mixture.

Consideration of the RCE application is respectfully requested.

Respectfully Submitted



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